

**Amendments to the Claims**

This listing of claims will replace all prior versions, and listings, of claims in the application:

**Listing of Claims:**

Claims 1-3 (canceled).

Claim 4 (currently amended). A process ~~according to claim 1~~ for dyeing or printing textile fibre materials, comprising applying a dyeing preparation in the form of an aqueous dye bath or printing paste to the textile fibre material wherein the dyeing preparation comprises a gloss pigment A or B wherein pigment A comprises  
A(a) a core consisting of a substantially transparent or metallicity reflecting material and  
A(b) at least one coating consisting essentially of one or more silicon oxides wherein the molar ratio of oxygen to silicon is on average from 0.03 to 0.95,  
and pigment B comprises

B(a) a core consisting essentially of one or more silicon oxides wherein the molar ratio of oxygen to silicon is on average from 0.03 to 0.95 and

wherein the gloss pigment A has the following layer structure:

$\text{SiO}_2/\text{SiO}_x/\text{SiO}_y/\text{SiO}_x/\text{SiO}_2$ ,  $\text{SiO}_2/\text{SiO}_x/\text{SiO}_2/\text{SiO}_x/\text{SiO}_2$ ,  $\text{SiO}_2/\text{SiO}_x/\text{Al}/\text{SiO}_x/\text{SiO}_2$ ,  
 $\text{TiO}_2/\text{SiO}_2/\text{SiO}_x/\text{SiO}_2/\text{SiO}_x/\text{SiO}_2/\text{TiO}_2$  or  $\text{TiO}_2/\text{SiO}_2/\text{SiO}_x/\text{Al}/\text{SiO}_x/\text{SiO}_2/\text{TiO}_2$ , wherein x is from 0.03 to 0.95 and y is from 0.95 to 1.8.

Claim 5 (original). A process according to claim 4, wherein the gloss pigment A has the following layer structure:  $\text{SiO}_2/\text{SiO}_x/\text{SiO}_y/\text{SiO}_x/\text{SiO}_2$ ,  $\text{SiO}_2/\text{SiO}_x/\text{SiO}_2/\text{SiO}_x/\text{SiO}_2$  or  $\text{TiO}_2/\text{SiO}_2/\text{SiO}_x/\text{SiO}_2/\text{SiO}_x/\text{SiO}_2/\text{TiO}_2$ , wherein x is from 0.03 to 0.95 and y is from 0.95

to 1.8, the core is a platelet having an average diameter of from 1 to 50  $\mu\text{m}$  and a thickness of from 20 to 500 nm, the thickness of the  $\text{SiO}_x$  layer is from 5 to 200 nm, the thickness of the  $\text{SiO}_y$  or  $\text{SiO}_2$  layer is from 1 to 200 nm, and the thickness of the  $\text{TiO}_2$  layer is from 1 to 180 nm.

Claims 6-20 (canceled).